

Lecture 3: CMOS Logic

Digital CMOS VLSI Design

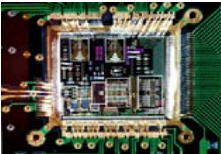
Instructor: Saraju P. Mohanty, Ph. D.

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Lecture Outline

- MOS Transistors
- CMOS Logic

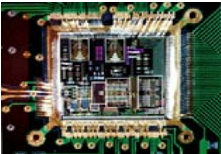


Introduction

- Integrated circuits: many transistors on one chip.
- *Very Large Scale Integration (VLSI)*: very many
- *Complementary Metal Oxide Semiconductor*
 - Fast, cheap, low power transistors
- How to build your own simple CMOS chip
 - CMOS transistors
 - Building logic gates from transistors
 - Transistor layout and fabrication

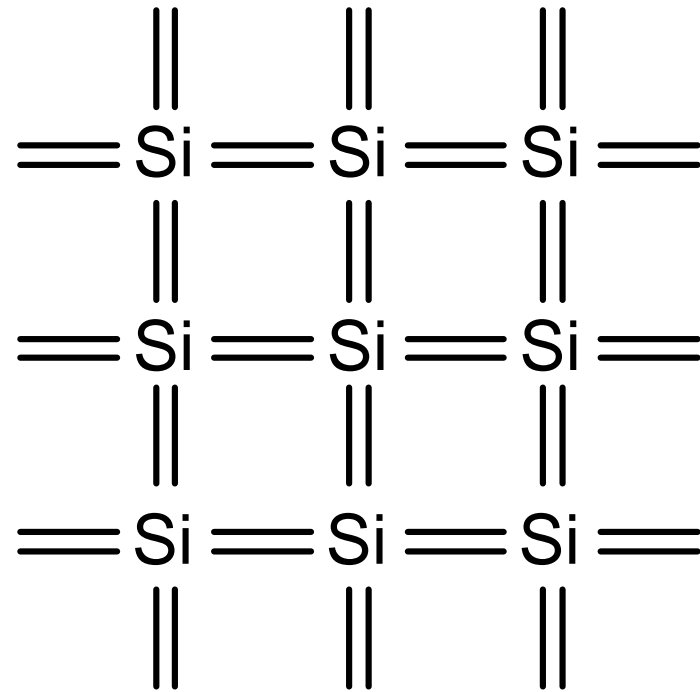


Silicon



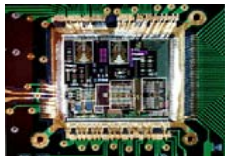
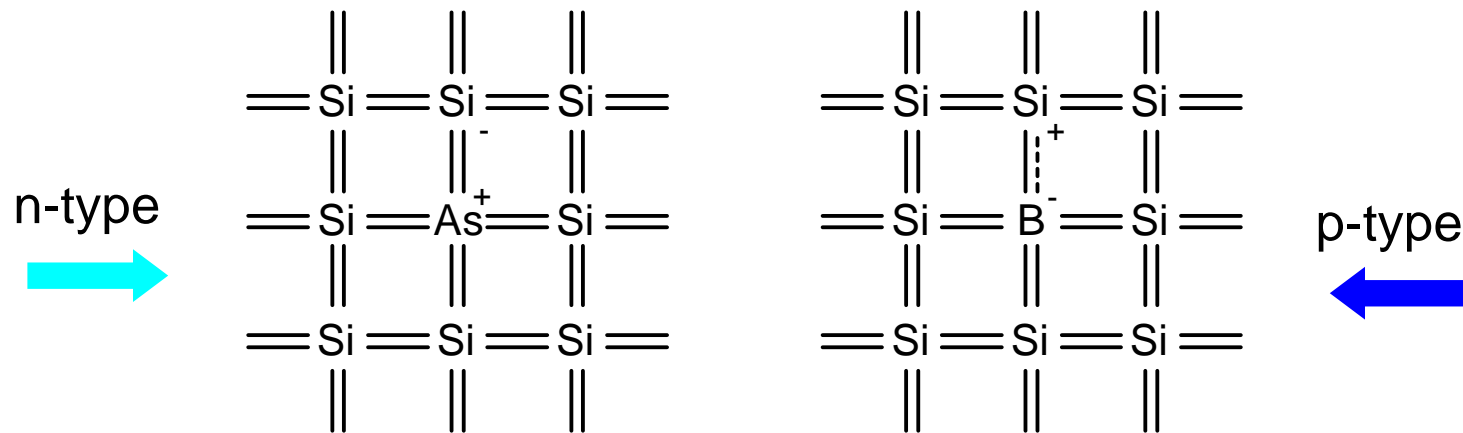
Silicon Lattice

- Transistors are built on a silicon substrate.
- Silicon is a Group IV material.
- Forms crystal lattice with bonds to four neighbors.



Dopants

- Silicon is a semiconductor.
- Pure silicon has no free carriers and conducts poorly.
- Adding dopants increases the conductivity.
- Group V: extra electron (n-type).
- Group III: missing electron, called hole (p-type).



Why Silicon?

Could any other group IV metal serve purpose ?

Key Advantages:

- Available abundantly in nature.
- Has excellent physical and electrical properties.
- Matured chemistry for fabrication.

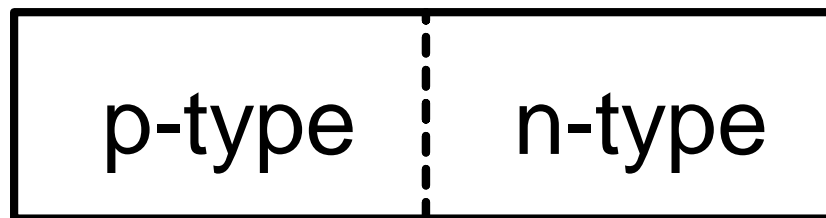


Devices

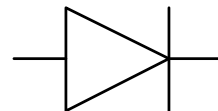


p-n Junctions

- A junction between p-type and n-type semiconductor forms a diode.
- Current flows only in one direction.



anode cathode

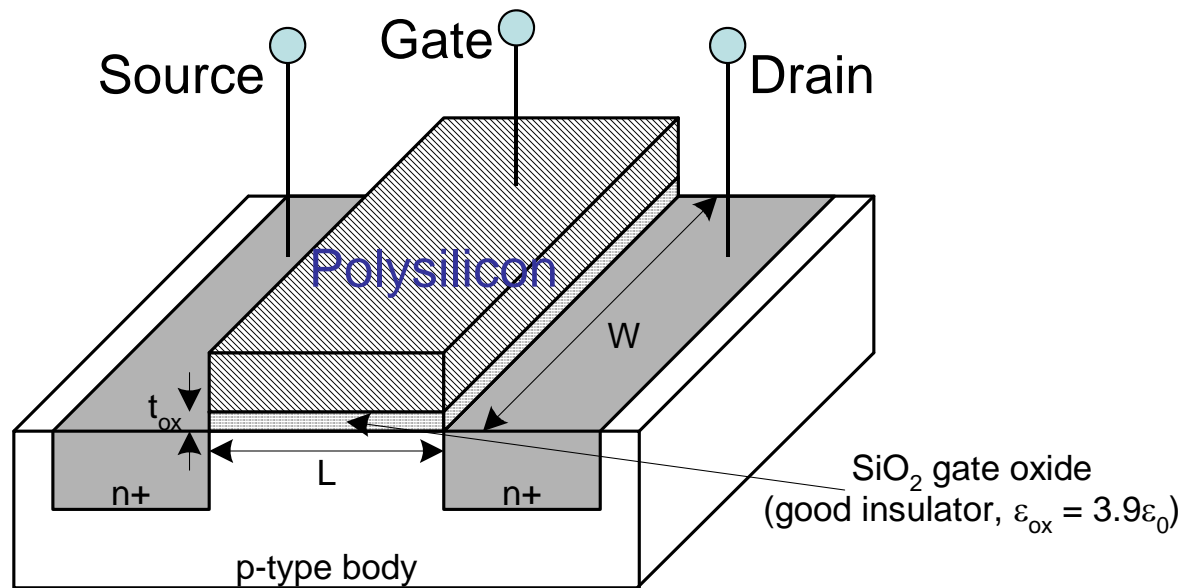


symbol



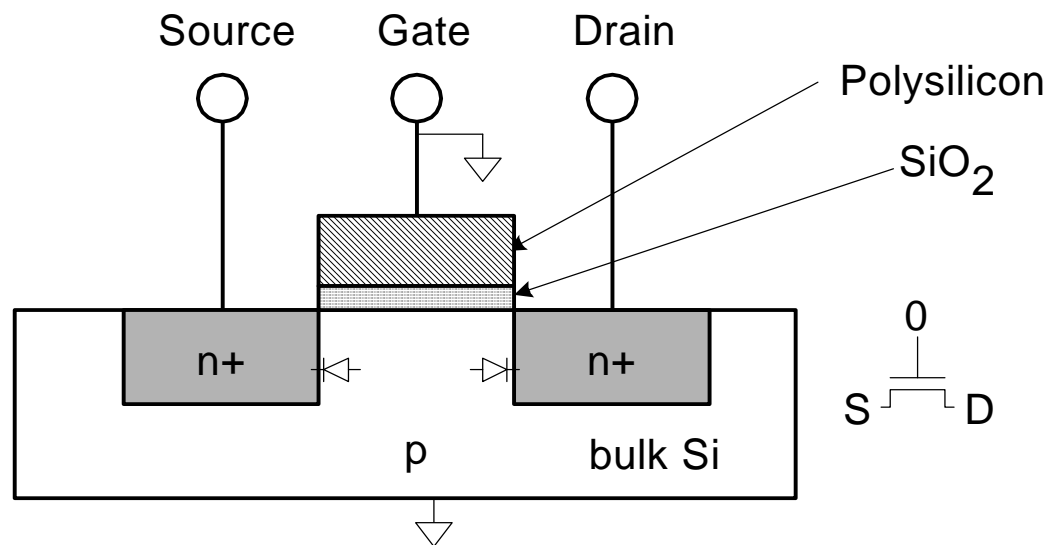
MOS Transistor

- Four terminals: gate, source, drain, body (bulk, or substrate)
- Gate – oxide – body stack looks like a capacitor
 - Gate and body are conductors
 - SiO_2 (oxide) is a very good insulator
 - Called metal – oxide – semiconductor (MOS) capacitor
 - Even though gate is no longer made of metal



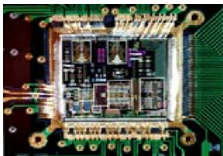
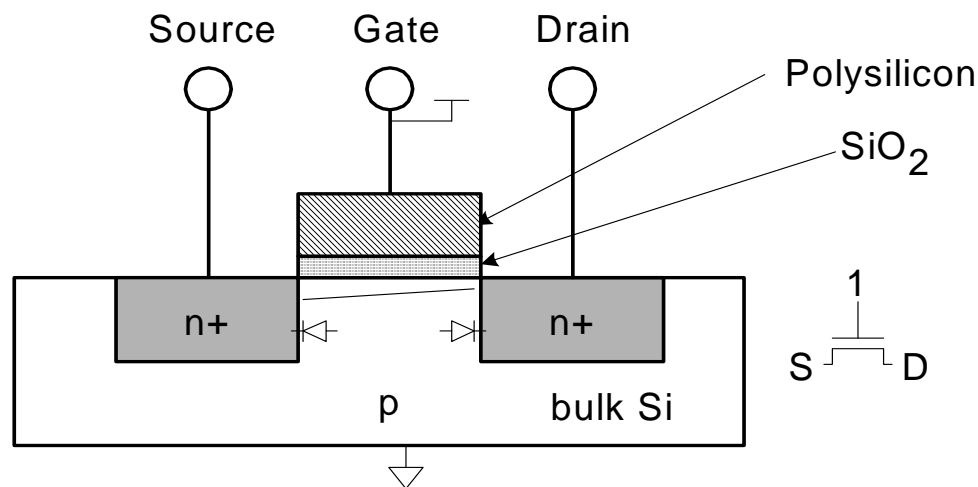
NMOS Operation

- Body is commonly tied to ground (0 V).
- When the gate is at a low voltage:
 - P-type body is at low voltage
 - Source-body and drain-body diodes are OFF
 - No current flows, transistor is OFF



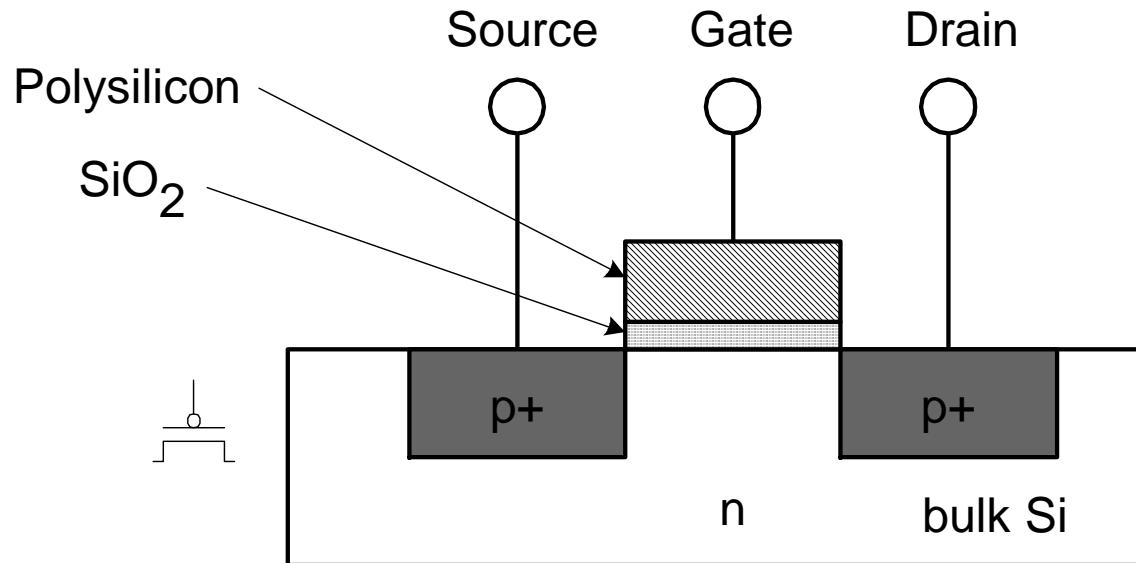
NMOS Operation

- When the gate is at a high voltage:
 - Positive charge on gate of MOS capacitor
 - Negative charge attracted towards gate
 - Inverts a channel under gate to n-type
 - Now current can flow through n-type silicon from source through channel to drain, transistor is ON



PMOS Transistor

- Similar, but doping and voltages reversed
 - Body tied to high voltage (V_{DD})
 - Gate low: transistor ON
 - Gate high: transistor OFF
 - Bubble indicates inverted behavior



Power Supply Voltage

- $GND = 0\text{ V}$
- In 1980's, $V_{DD} = 5\text{V}$
- V_{DD} has decreased in modern processes
 - High V_{DD} would damage modern tiny transistors
 - Lower V_{DD} saves power
- $V_{DD} = 3.3, 2.5, 1.8, 1.5, 1.2, 1.0, \dots$
- For 65nm or 45nm it is approximately 0.7V.

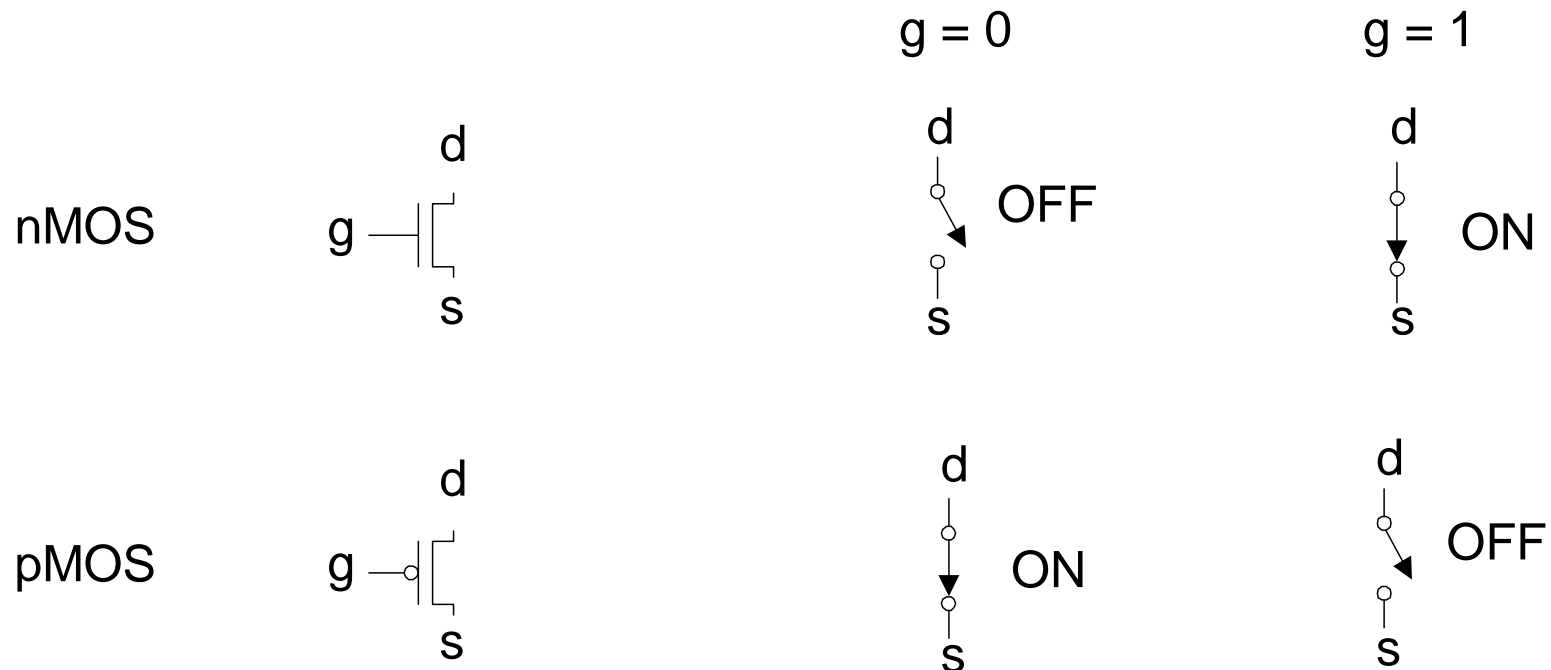


CMOS Circuits with Transistor as Switch



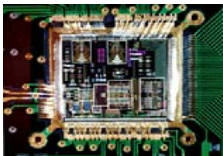
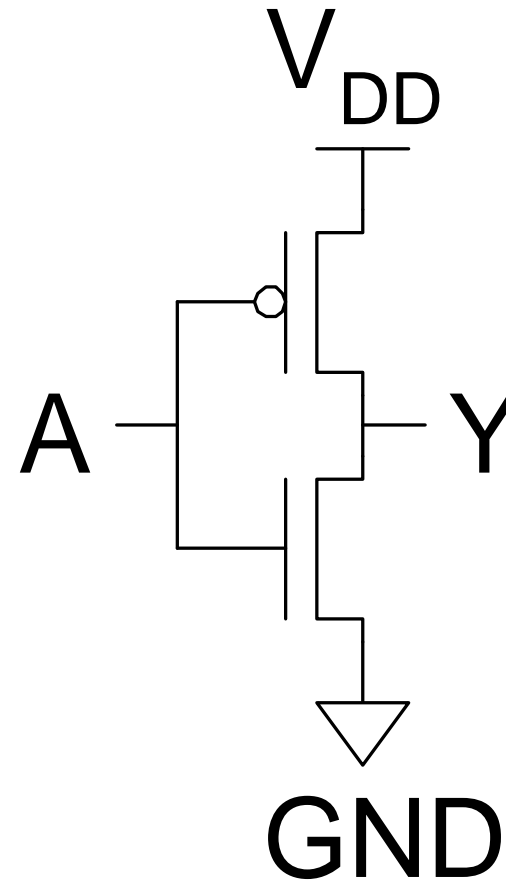
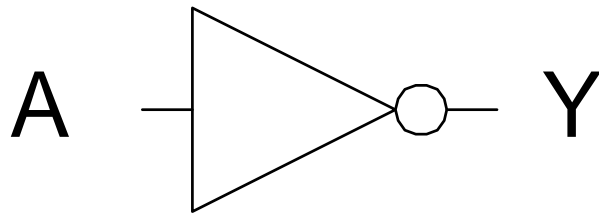
Transistors as Switches: Ideal

- We can view MOS transistors as electrically controlled switches.
- Voltage at gate controls path from source to drain.



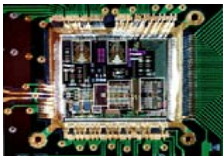
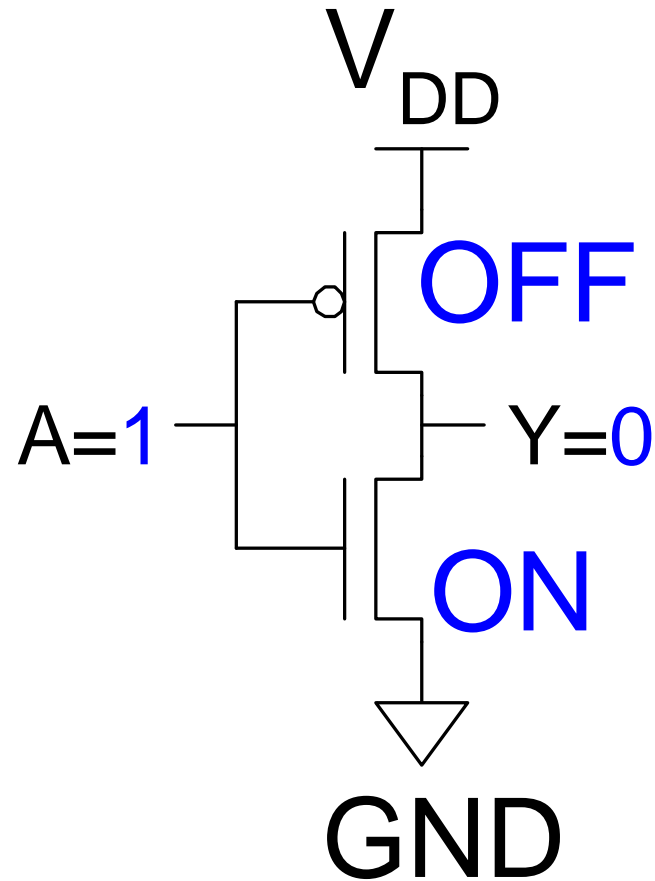
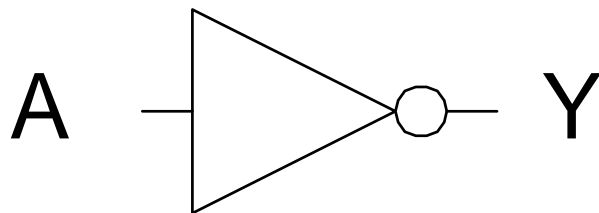
CMOS Inverter

A	Y
0	
1	



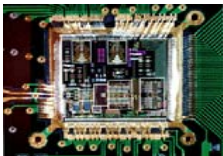
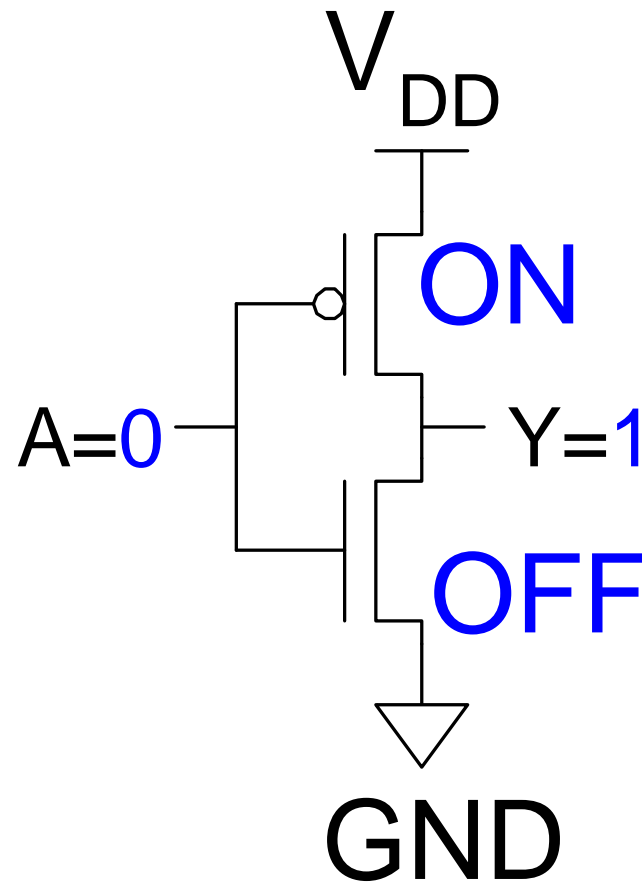
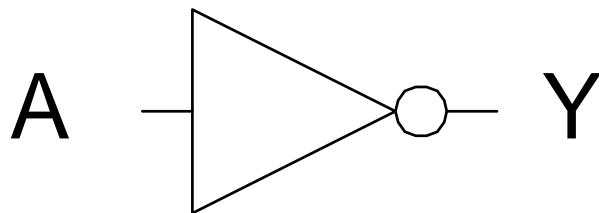
CMOS Inverter

A	Y
0	
1	0



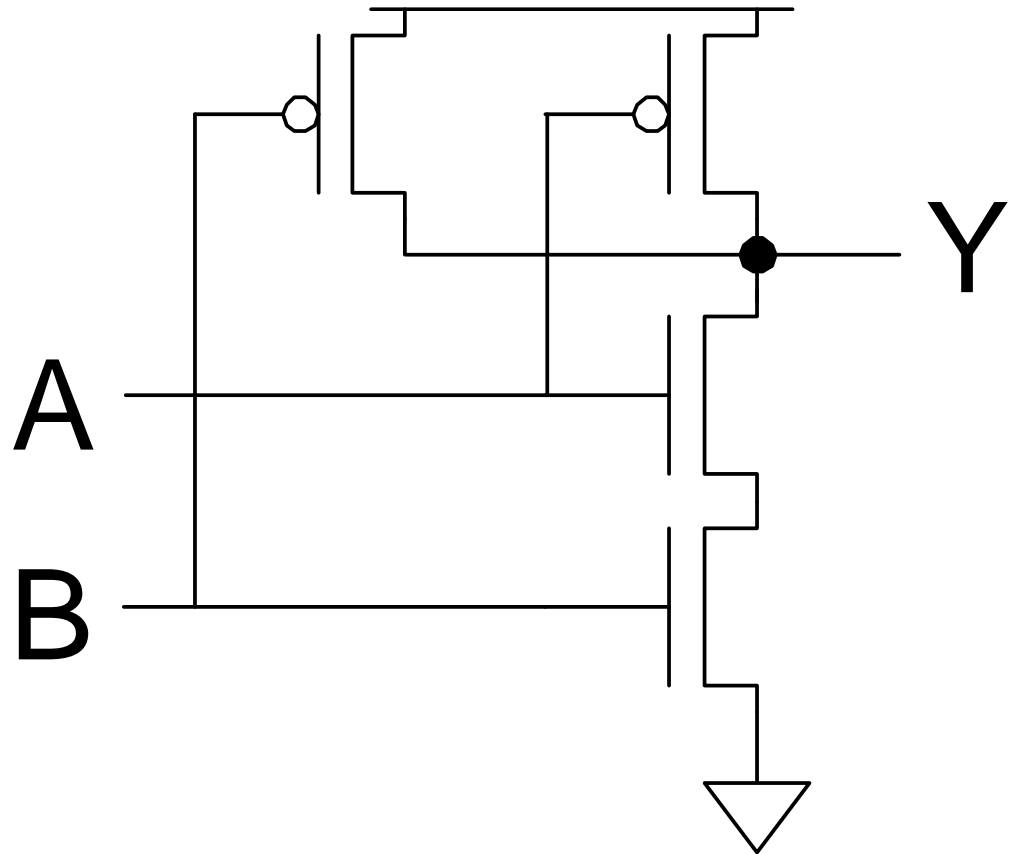
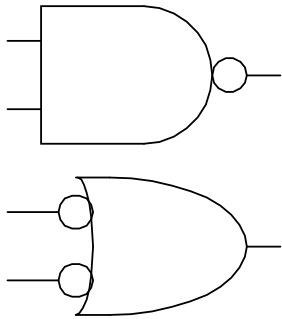
CMOS Inverter

A	Y
0	1
1	0



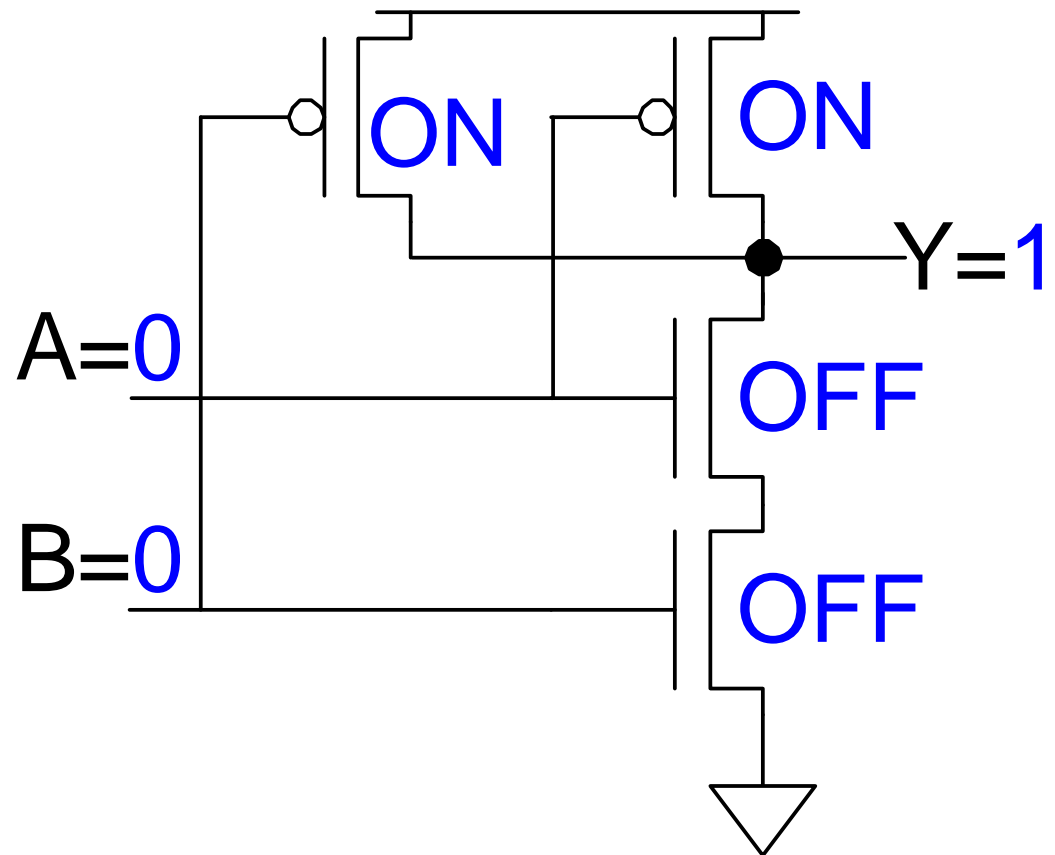
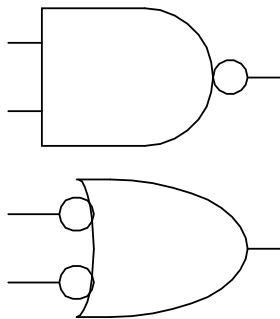
CMOS NAND Gate

A	B	Y
0	0	
0	1	
1	0	
1	1	



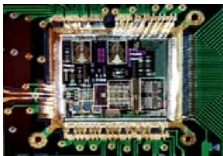
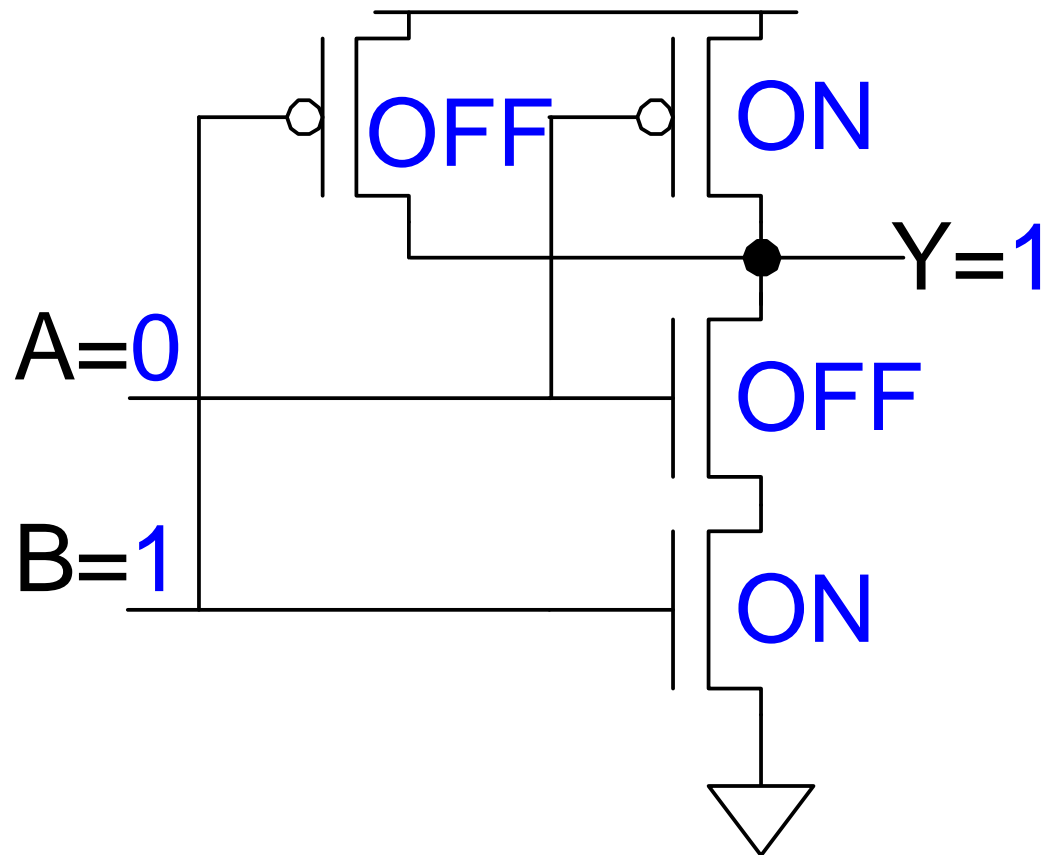
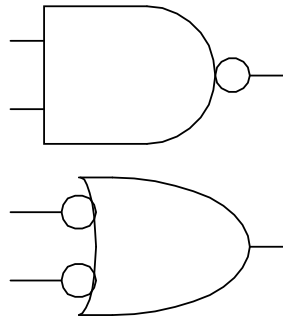
CMOS NAND Gate

A	B	Y
0	0	1
0	1	
1	0	
1	1	



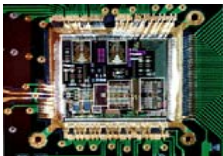
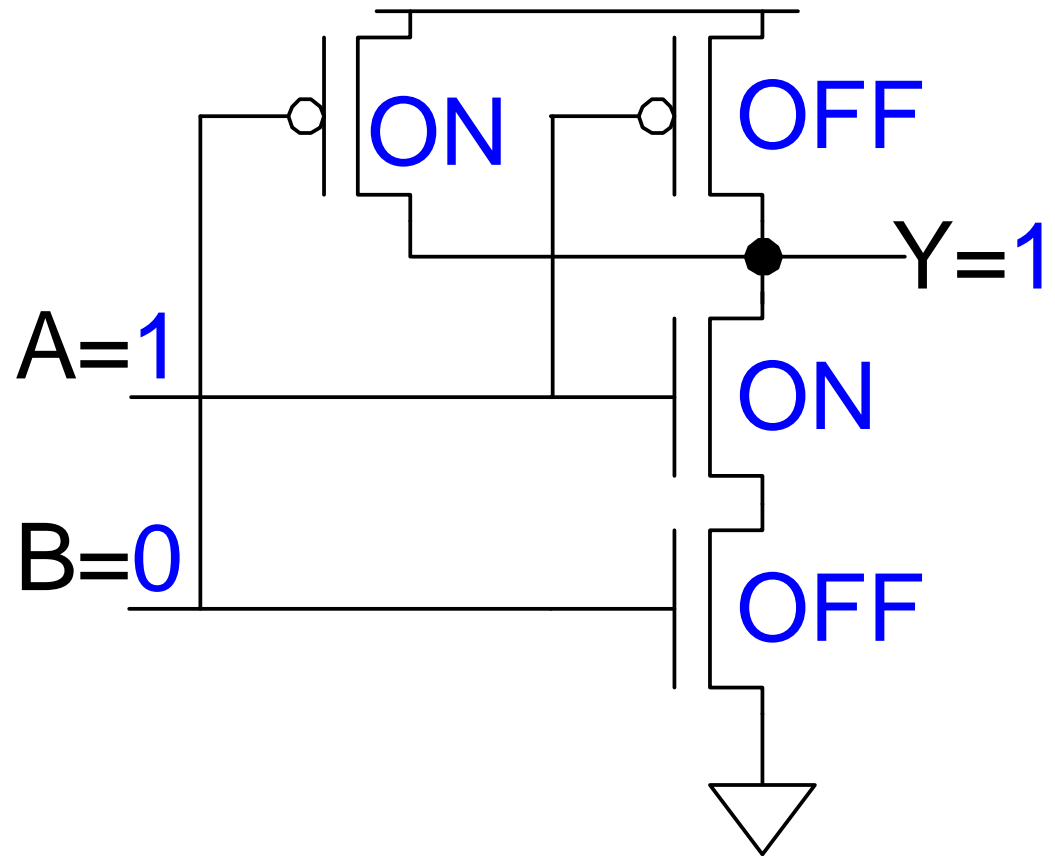
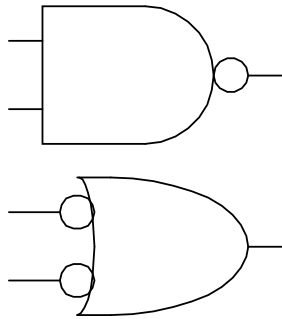
CMOS NAND Gate

A	B	Y
0	0	1
0	1	1
1	0	
1	1	



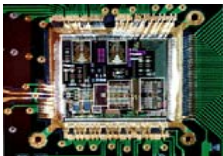
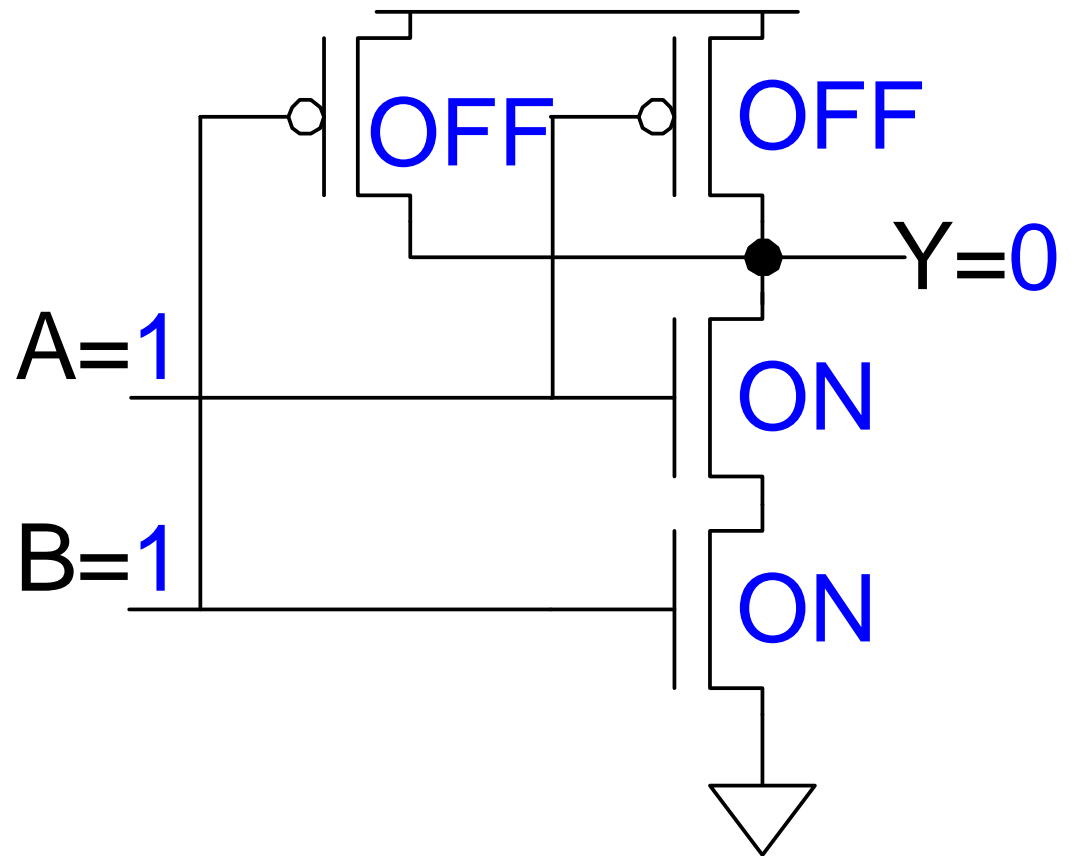
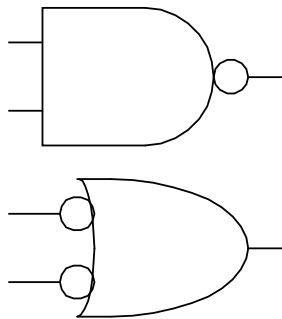
CMOS NAND Gate

A	B	Y
0	0	1
0	1	1
1	0	1
1	1	



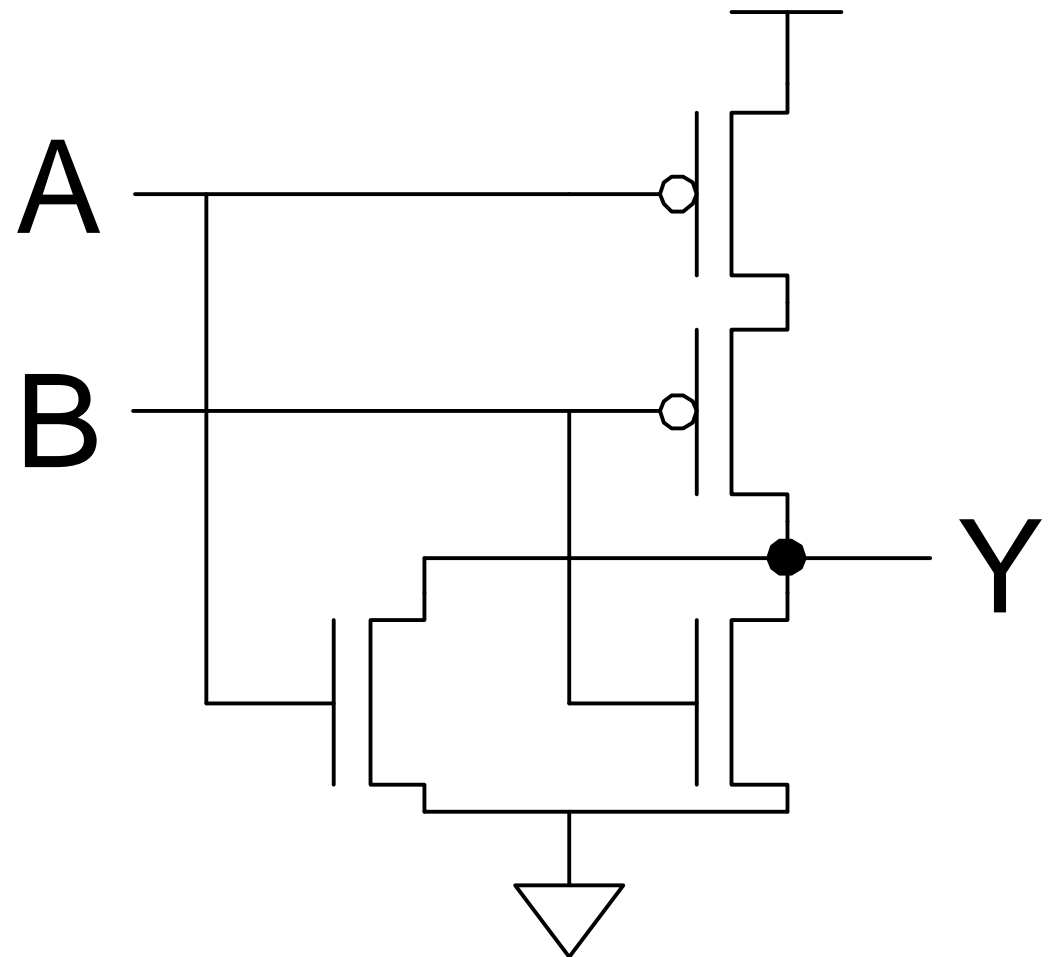
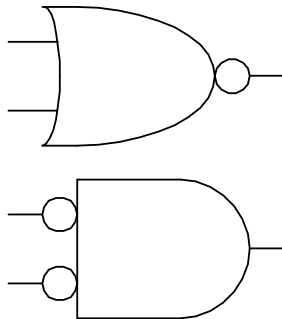
CMOS NAND Gate

A	B	Y
0	0	1
0	1	1
1	0	1
1	1	0



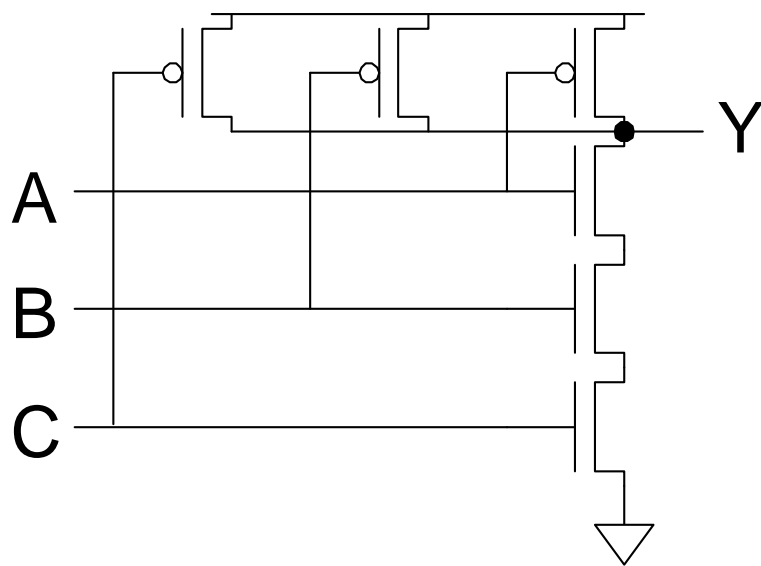
CMOS NOR Gate (Dual of NAND)

A	B	Y
0	0	1
0	1	0
1	0	0
1	1	0

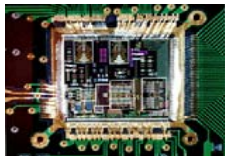
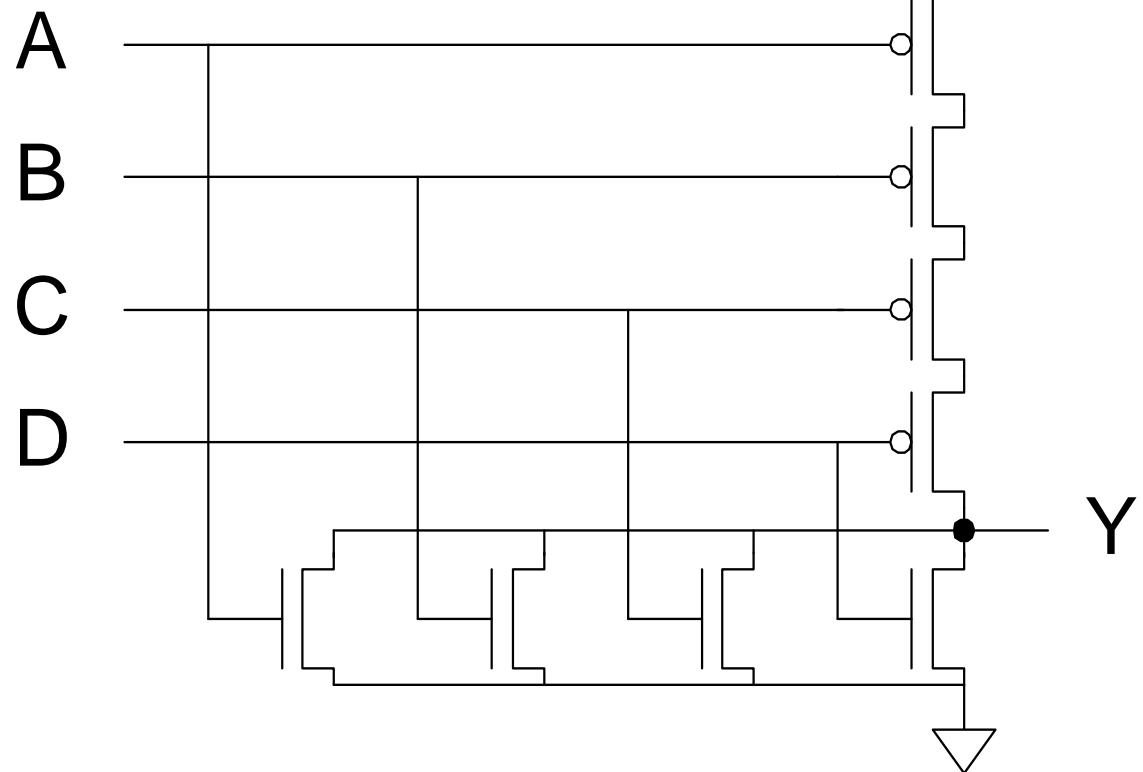


3-input NAND / 4-input NOR Gate

- Y pulls low if ALL inputs are 1
- Y pulls high if ANY input is 0



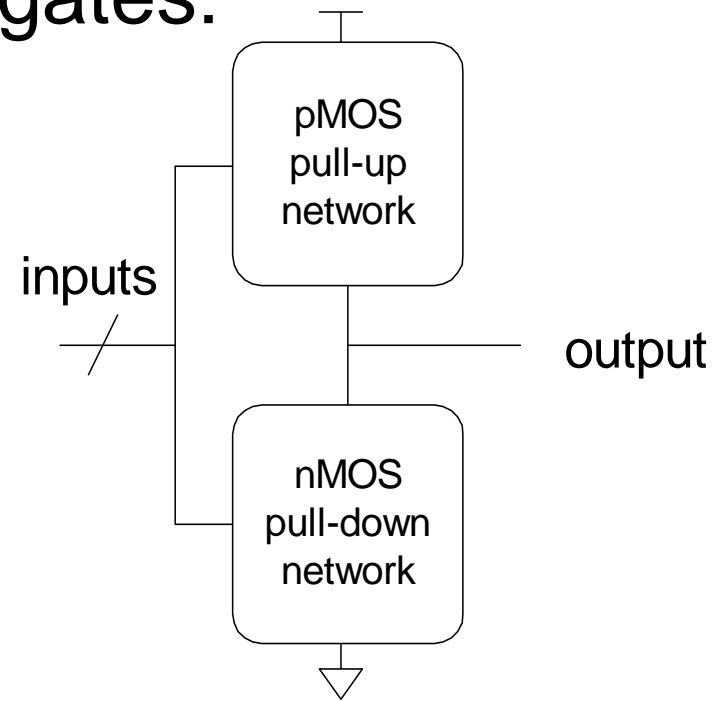
4-input NOR Gate



Complementary CMOS : General

- Complementary CMOS logic gates:

- NMOS *pull-down network*
- PMOS *pull-up network*
- *a.k.a.* static CMOS

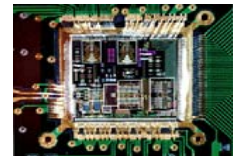
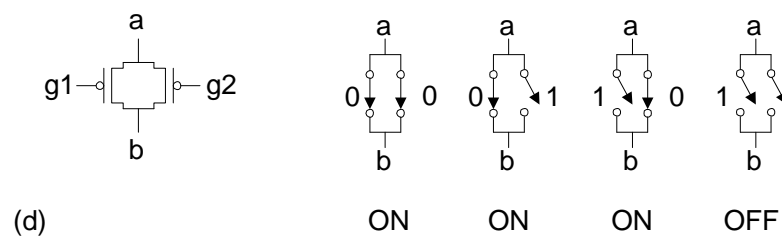
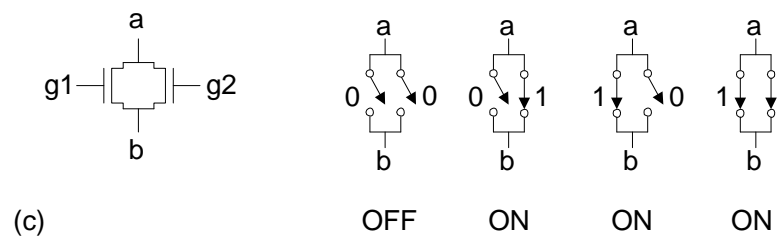
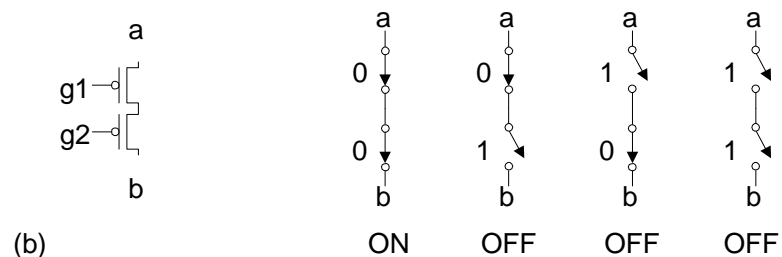
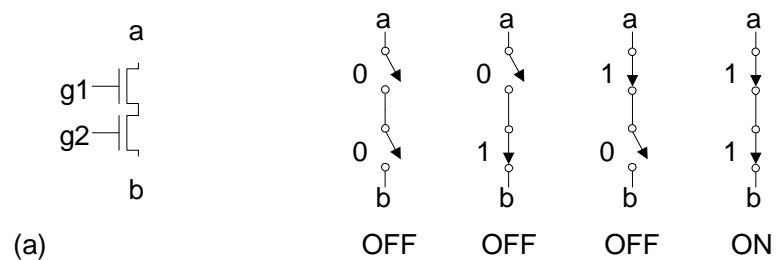


	Pull-up OFF	Pull-up ON
Pull-down OFF	Z (float)	1
Pull-down ON	0	X (crowbar)



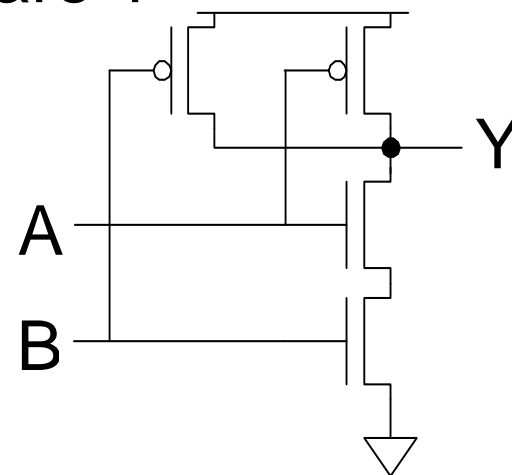
Connection and Behavior of Transistors

- NMOS: 1 = ON
- PMOS: 0 = ON
- *Series*: both must be ON
- *Parallel*: either can be ON



Conduction Complement

- Complementary CMOS gates always produce 0 or 1.
- Example: NAND gate
 - Series NMOS: $Y=0$ when both inputs are 1
 - Thus $Y=1$ when either input is 0
 - Requires parallel PMOS
- Rule of *Conduction Complements*
 - Pull-up network is complement of pull-down
 - Parallel \rightarrow series, series \rightarrow parallel



Signal Strength

- *Strength* of signal
 - How close it approximates ideal voltage source?
- V_{DD} and GND rails are strongest 1 and 0.
- NMOS pass strong 0
 - But degraded or weak 1
- PMOS pass strong 1
 - But degraded or weak 0
- Thus, NMOS are best for pull-down network.
- And, PMOS are best for pull-up network.



CMOS Transistor Synthesis of Boolean

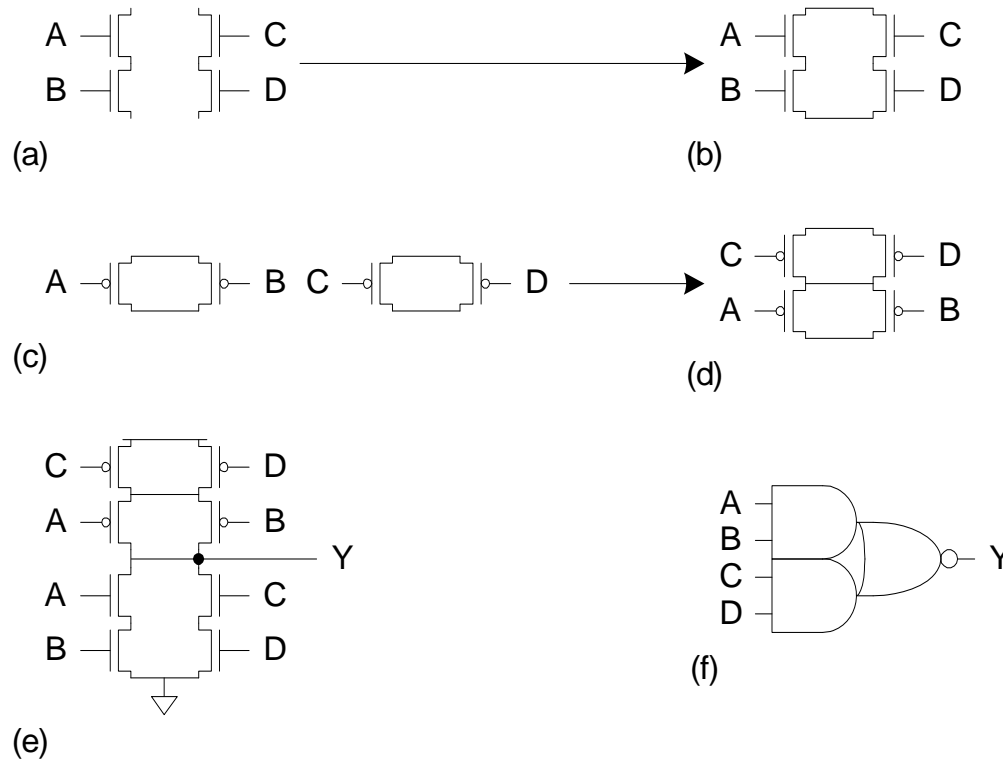
- Formed using combination of series and parallel switch structures.
- *Compound gates* can do any inverting function.
- Synthesis Steps:
 - Express the function in inverting form.
 - Do NMOS realization of the new function without inverting. Series is AND and parallel is OR.
 - Do PMOS realization which is dual of NMOS. Dual means NMOS becomes PMOS, series becomes parallel and parallel becomes series.
 - Connect the NMOS and PMOS realizations. Connecting point is the output point.



Compound Gates

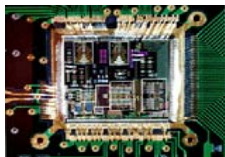
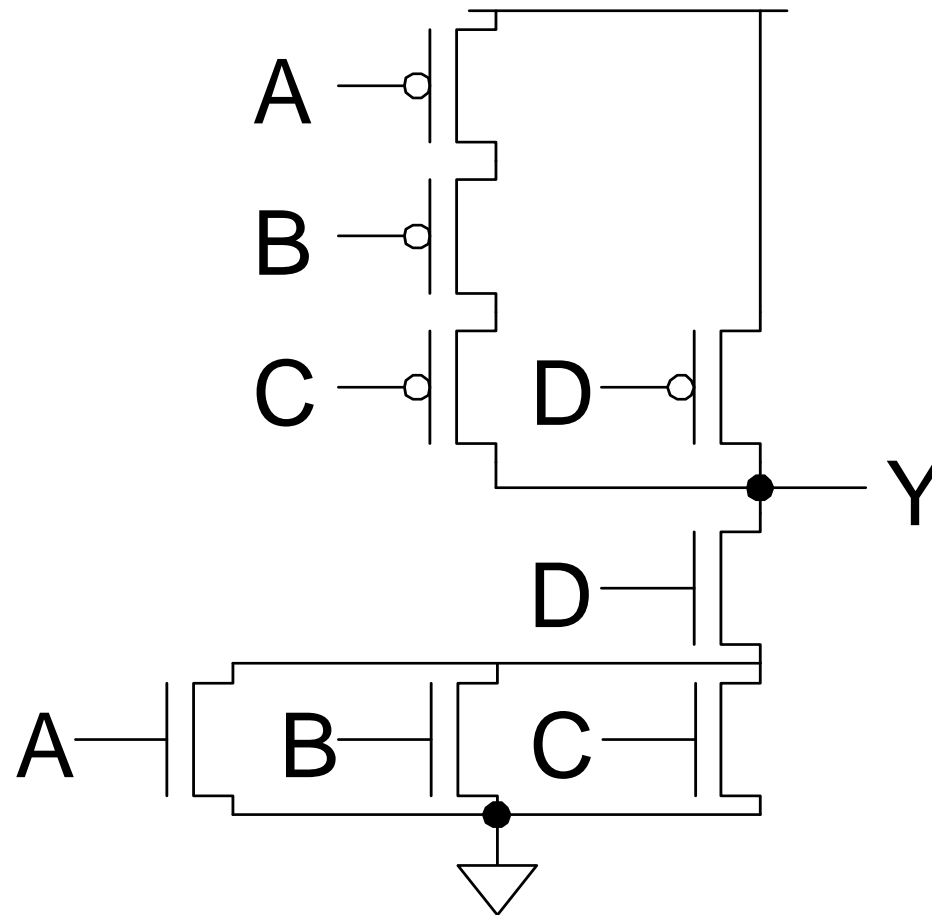
- Example:

$$Y = \overline{A \square B + C \square D} \text{ (AND-AND-OR-INVERT)}$$



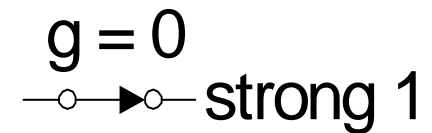
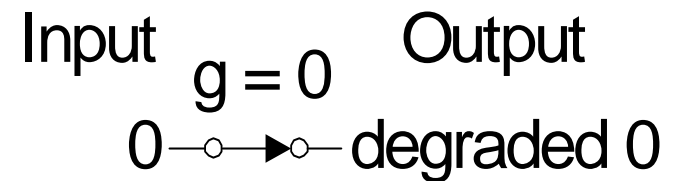
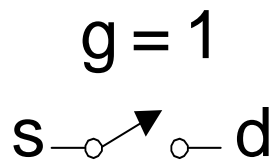
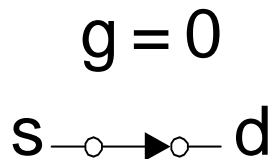
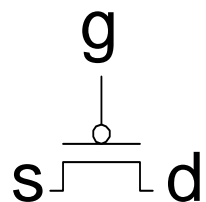
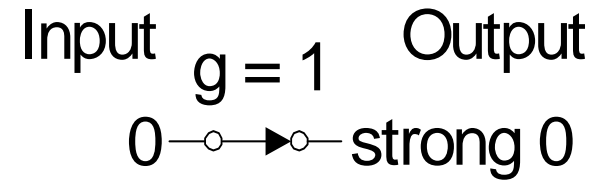
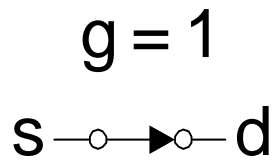
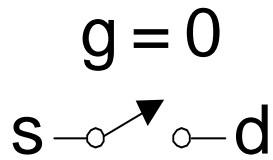
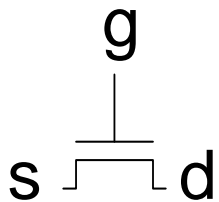
Compound Gates ...

Example: $Y = \overline{(A + B + C)} \square D$



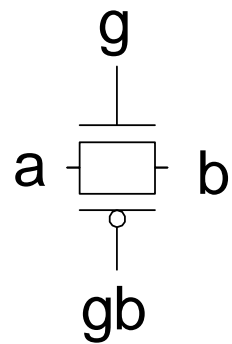
Pass Transistors

- Transistors can be used as switches.

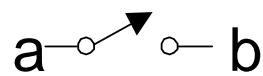


Transmission Gates

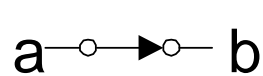
- Pass transistors produce degraded outputs.
- *Transmission gates* pass both 0 and 1 well.



$$g = 0, gb = 1$$



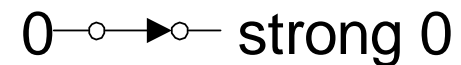
$$g = 1, gb = 0$$



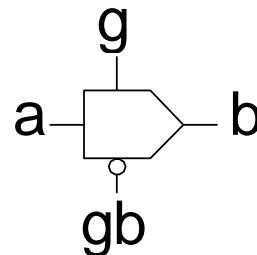
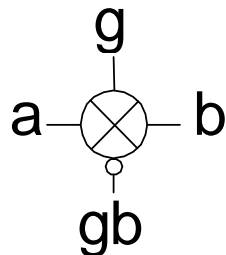
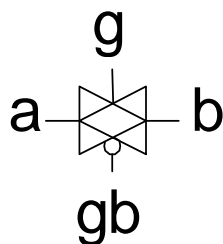
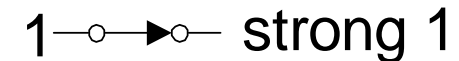
Input

Output

$$g = 1, gb = 0$$



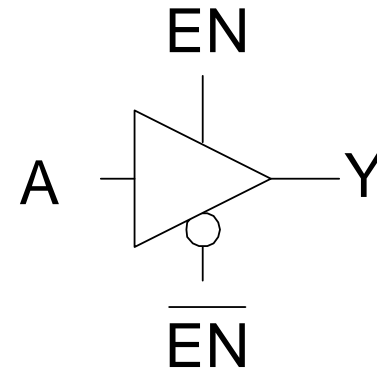
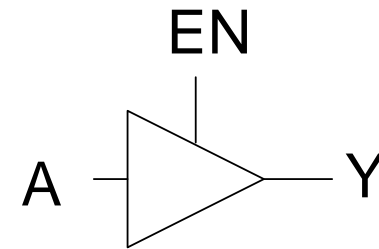
$$g = 1, gb = 0$$



Tristate Buffer

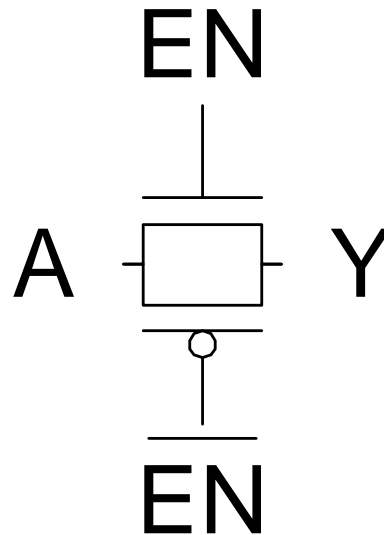
- *Tristate buffer* produces Z when not enabled.

EN	A	Y
0	0	Z
0	1	Z
1	0	0
1	1	1



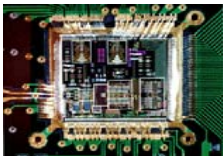
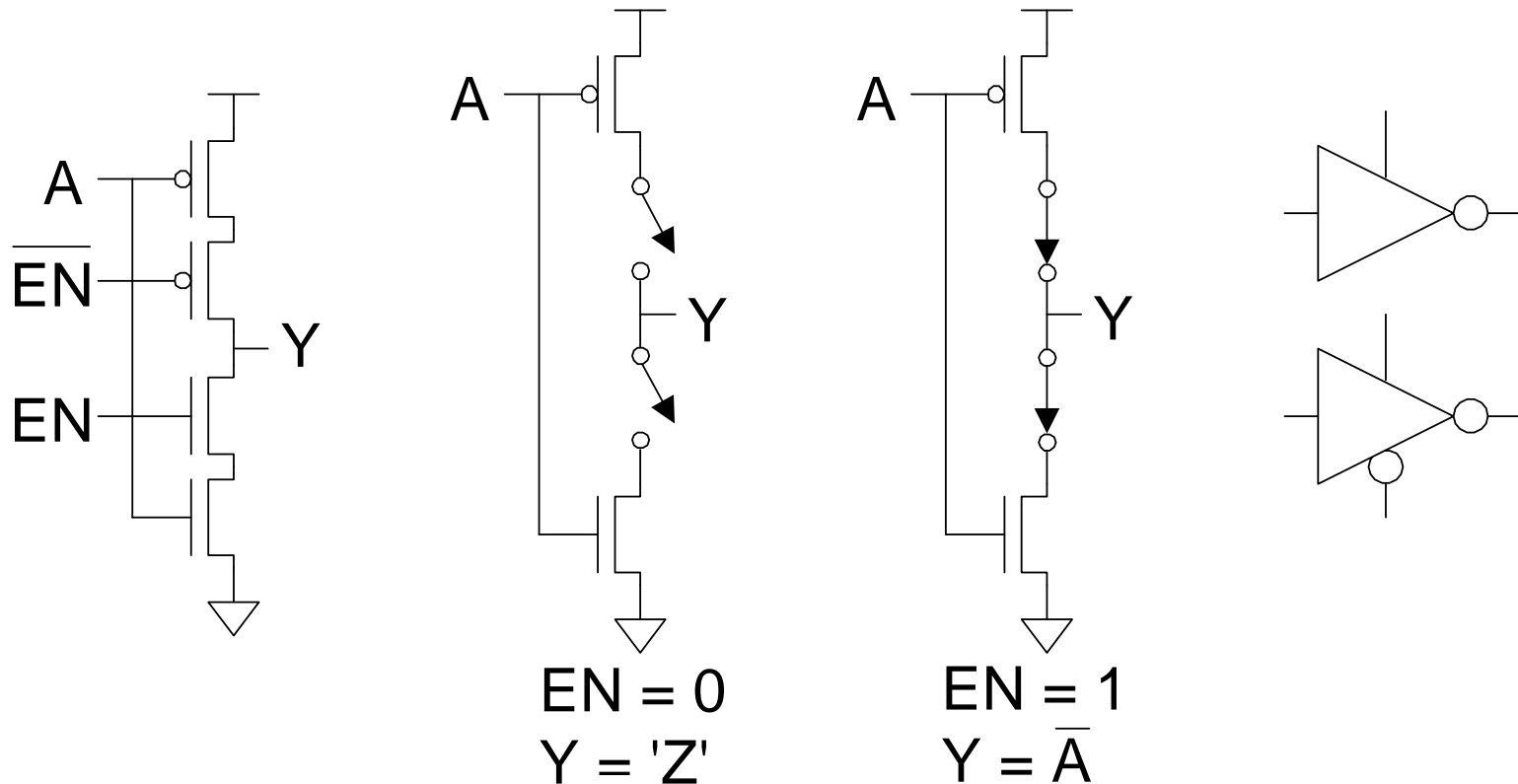
Nonrestoring Tristate Buffer

- Transmission gate acts as tristate buffer.
 - Only two transistors
 - But *nonrestoring*
 - Noise on A is passed on to Y



Tristate Inverter

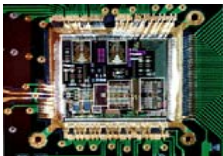
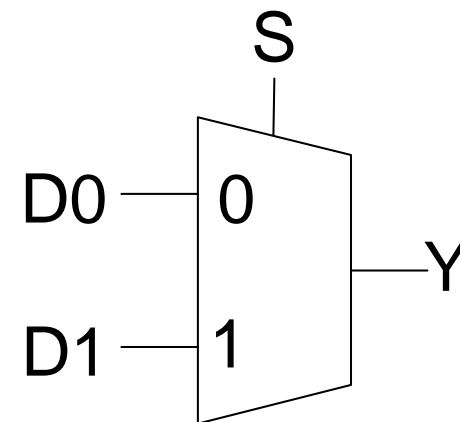
- Tristate inverter produces restored output.
 - Violates conduction complement rule
 - Because we want a Z output



Multiplexers

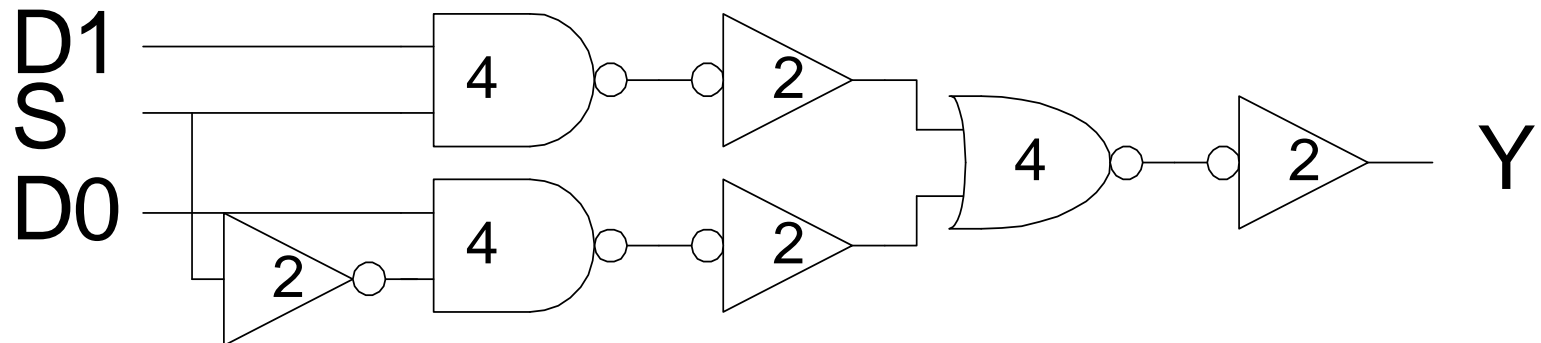
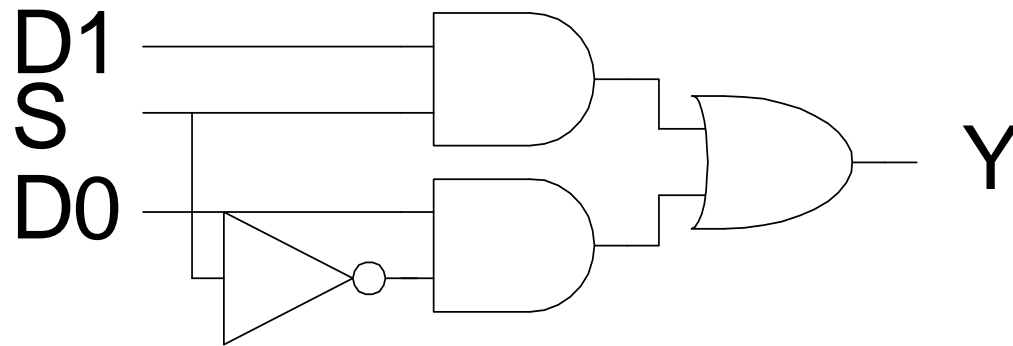
- 2:1 multiplexer chooses between two inputs.

S	D1	D0	Y
0	X	0	0
0	X	1	1
1	0	X	0
1	1	X	1



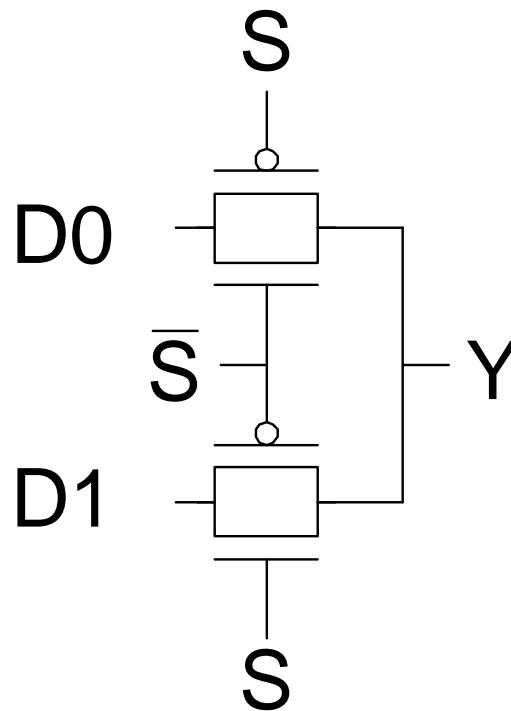
Multiplexers Design : One Approach

- $Y = SD_1 + \bar{S}D_0$ (too many transistors)
- How many transistors are needed? 20



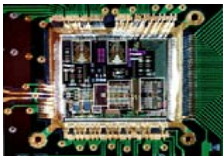
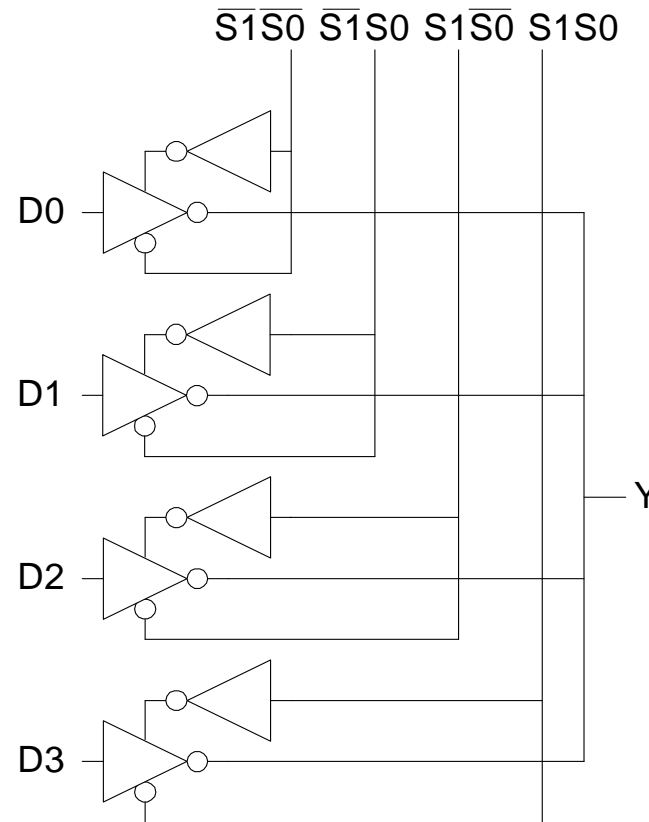
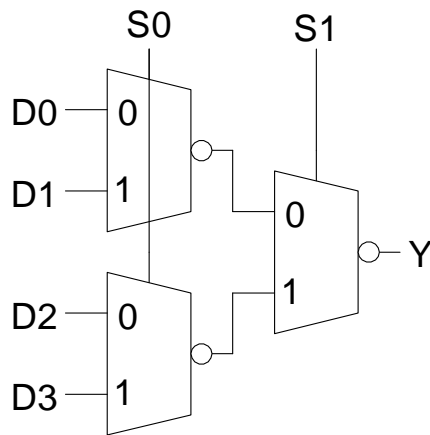
Multiplexers Design : 2nd Approach

- Nonrestoring mux uses two transmission gates.
 - Only 4 transistors



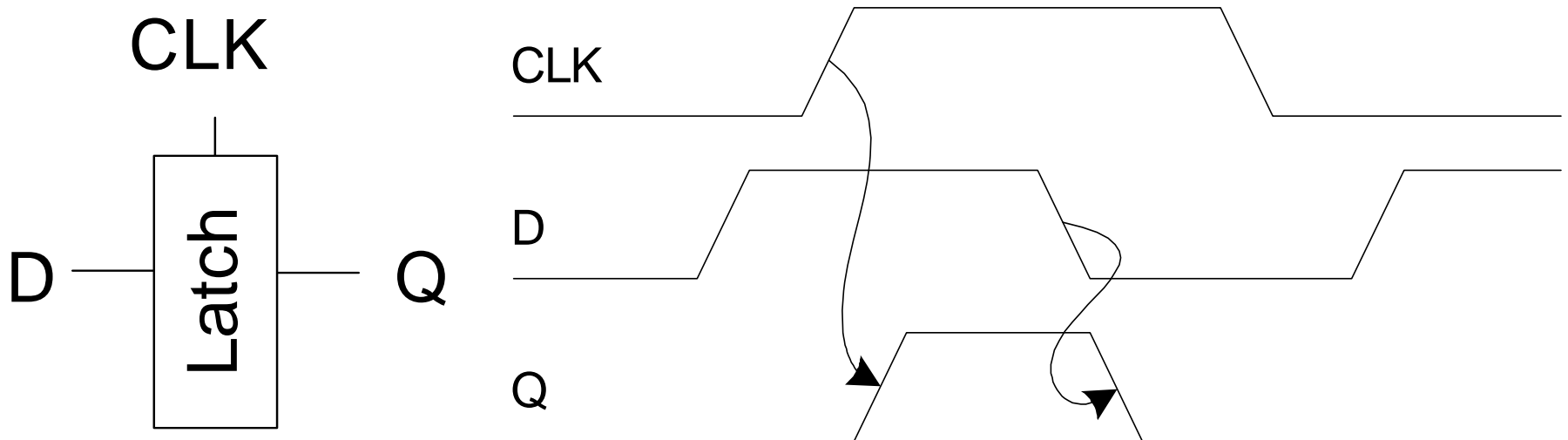
4:1 Multiplexer

- 4:1 mux chooses one of 4 inputs using two selects.
 - Two levels of 2:1 muxes
 - Or four tristates



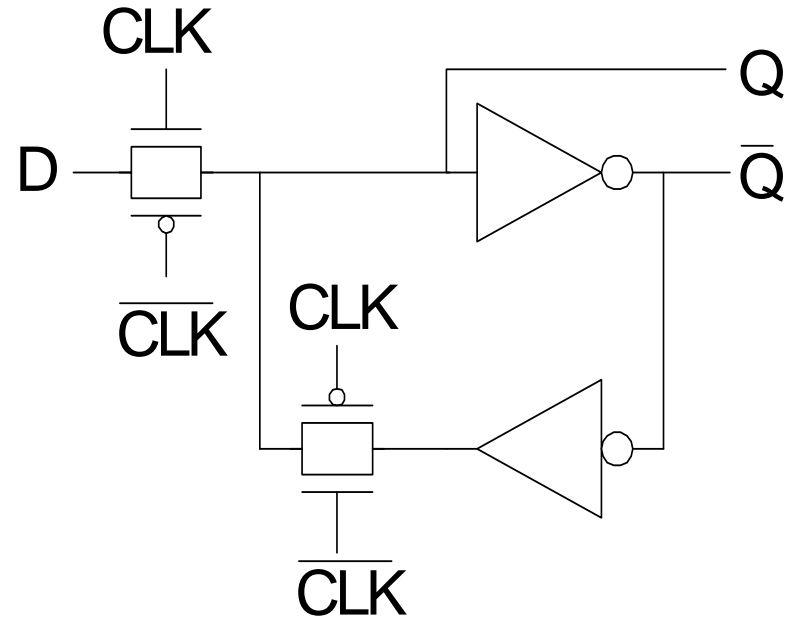
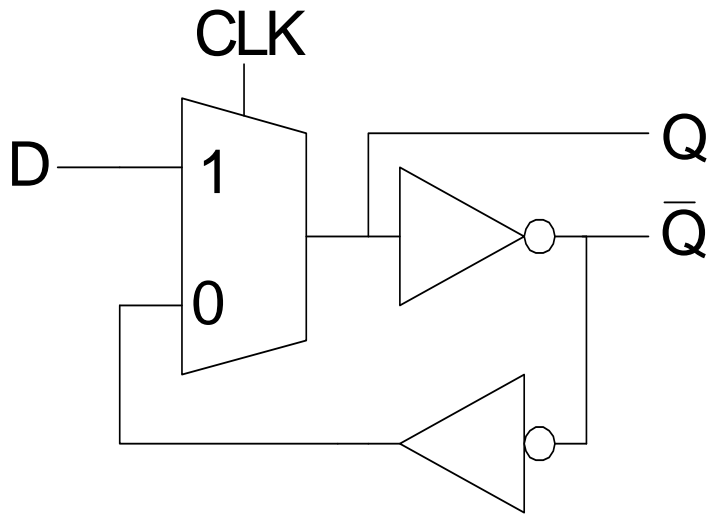
D Latch

- When $CLK = 1$, latch is *transparent*
 - D flows through to Q like a buffer
- When $CLK = 0$, the latch is *opaque*
 - Q holds its old value independent of D
- *a.k.a. transparent latch or level-sensitive latch.*

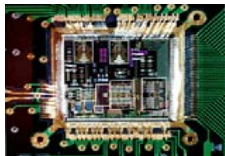
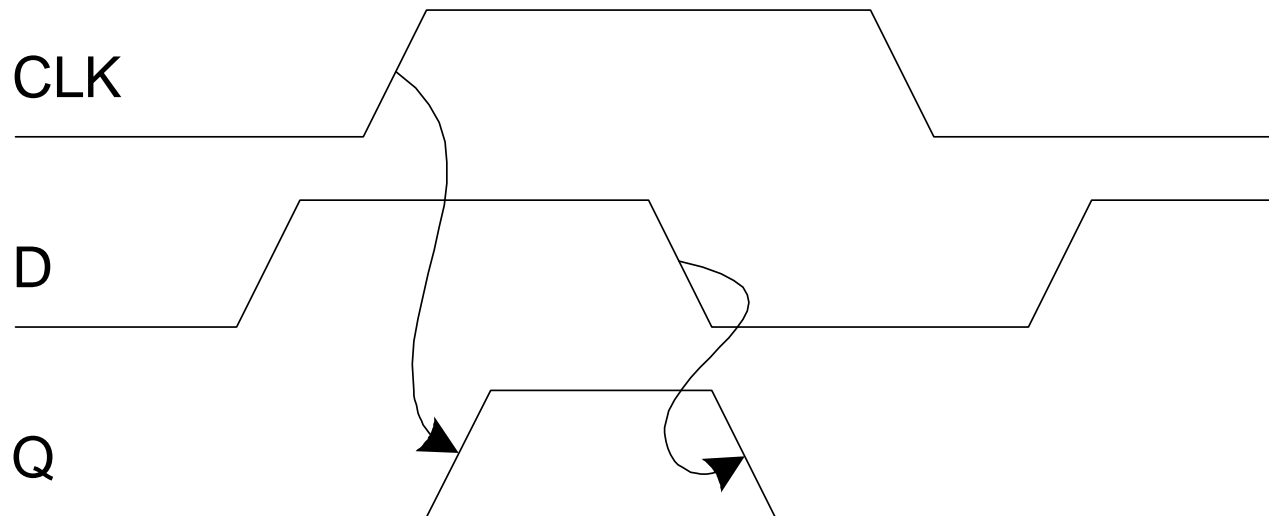
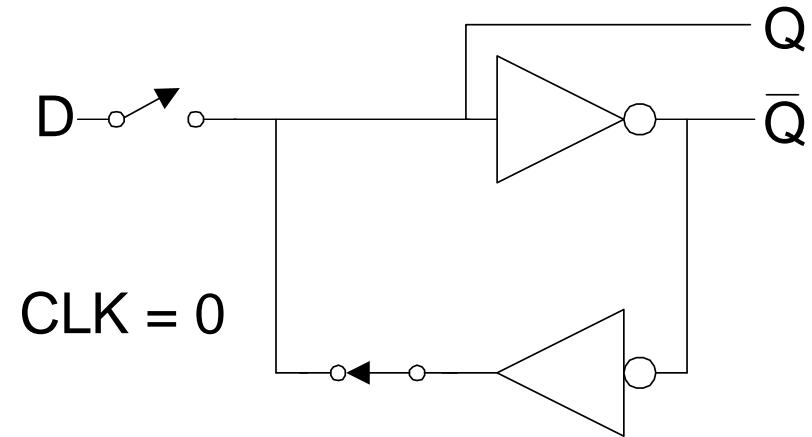
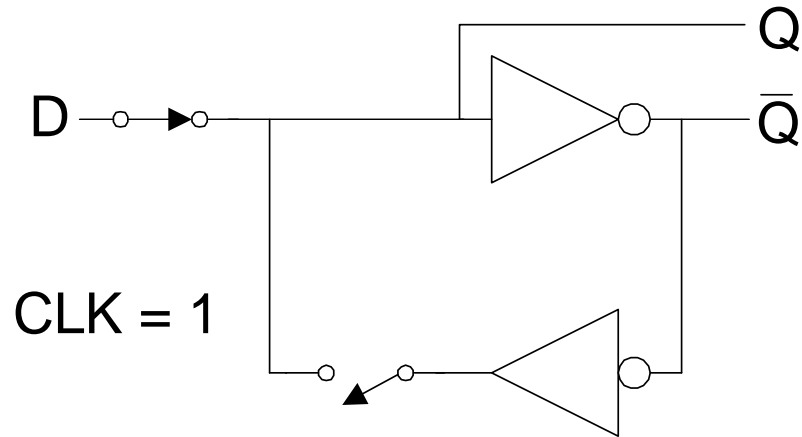


D Latch : Design

- Multiplexer chooses D or old Q.

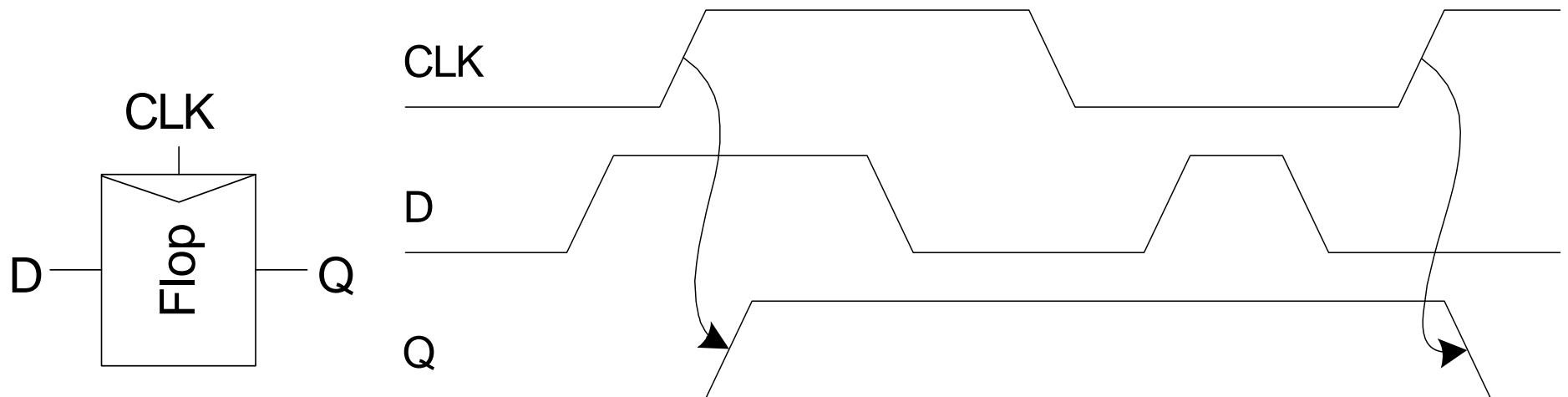


D Latch : Operation



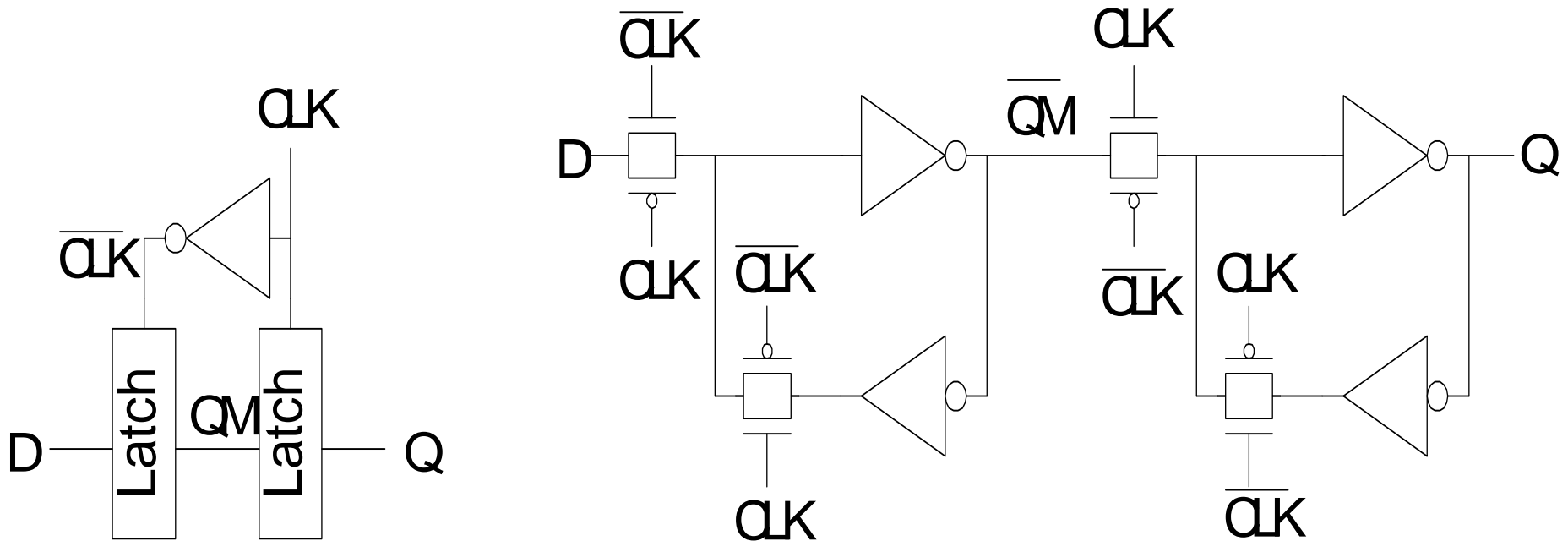
D Flip-flop

- When CLK rises, D is copied to Q.
- At all other times, Q holds its value.
- a.k.a. *positive edge-triggered flip-flop, master-slave flip-flop.*

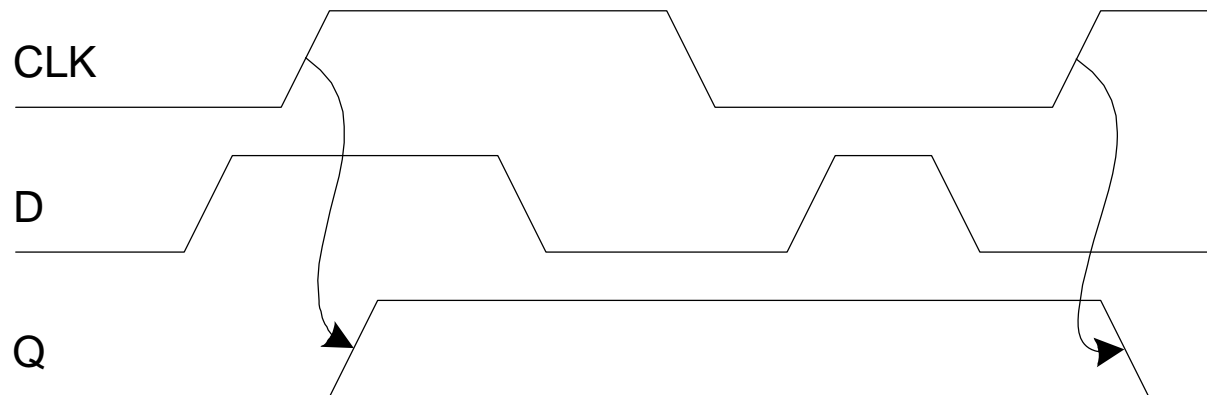
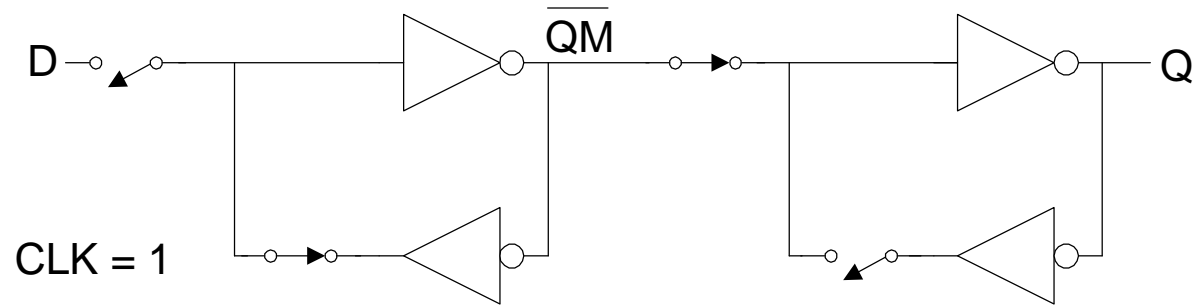
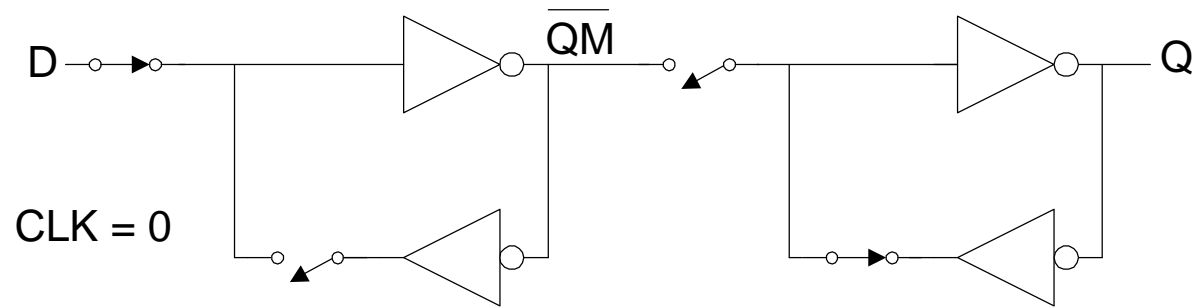


D Flip-flop : Design

- Built from master and slave D latches.

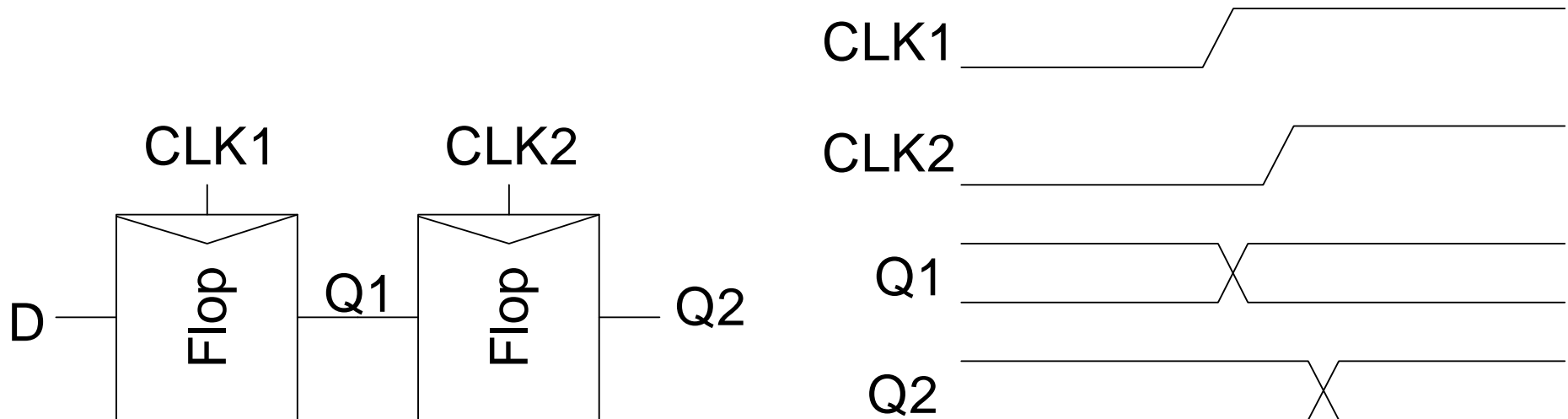


D Flip-flop : Operation



D-FF : Race Condition

- Back-to-back flops can malfunction from clock skew.
 - Second flip-flop fires late
 - Sees first flip-flop change and captures its result
 - Called *hold-time failure* or *race condition*



D-FF: Nonoverlapping Clocks

- Nonoverlapping clocks can prevent races.
 - As long as nonoverlap exceeds clock skew
- We will use them in this class for safe design.
 - Industry manages skew more carefully instead

